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Nuclear quadrupole interaction at ¹⁸¹Ta in hafnium dioxide fiber: Time differential perturbed angular correlation measurements and ab initio calculations

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ABSTRACT

The thermal behavior of hafnium dioxide fiber has been investigated with the aid of time differential perturbed angular correlation (TDPAC) technique along with XRD and SEM measurements. This study has proved a good thermal stability of the fibrous material up to 1173 K and the fiber loses its crystallinity to a meager extent at 1673 K. No phase transition has been observed up to 1673 K in this fiber. TDPAC parameters for the HfO₂ fiber annealed at 1173 K are ω_Q =124.6 (3) Mrad/s and η =0.36 (1). These values remain unaltered for the HfO₂ fiber annealed even at 1673 K. Electronic structure calculations based on the density functional theory (DFT) for HfO₂ doped with tantalum impurity have been performed and the calculated EFG parameters are in reasonable agreement with the experimental values.

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1. Introduction

A suitable refractory material which can be heated to elevated temperatures is an essential requirement for an efficient production of the radioactive ion beams (RIB) using the isotope separation on-line (ISOL) technique [1]. At a high temperature, there is a fast release of the product species from the target but at the same time there should not be sufficient vaporization or sublimation of the target material itself. Among various refractory materials viz. HfO_2 , Y_2O_3 , CeO_2 , Al_2O_3 etc. satisfying the physical, chemical, metallurgical and thermodynamical properties, hafnium oxide (HfO₂) has been considered as a potential RIB target material [1]. The temperature at which the vapor pressure of the target material reaches 10^{-4} Torr is the highest (2773 K) for HfO₂. Moreover, Hafnium being the highest Z element among the metal ions of the above mentioned materials, the stopping range of the recoil products is the least in HfO₂ and thus the reaction products cannot penetrate deep below the surface and would be released faster thereby increasing the efficiency of the RIB intensity. Fibrous targets of HfO2 have been used successfully for the production of the ¹⁷F radioactive beam [2]. It has been observed that the HfO₂ targets can be operated at higher temperatures (2373–2573 K) compared to the others leading to a more efficient release of the required radioactive isotopes [3]. The properties of the targets using HfO₂ in various forms are studied for the RIB facility which is being developed at Variable Energy Cyclotron Centre (VECC), Kolkata, incorporating the traditional ISOL technique [4]. According to the simulation studies, it is found that the temperature at the Al₂O₃ target would be 1000–2000 K depending on the energy deposited by the proton or alpha beam used for the irradiation. It is expected that the HfO₂ fibrous targets for the RIB production would be heated to such high temperatures under similar irradiation conditions. In addition, HfO₂ has several other applications [5,6] due to its high mechanical hardness, significant thermal stability and high refractive index. HfO₂ having a high dielectric constant can be considered as a gate dielectric in the form of thin film [7,8]. A recent study [9] describes the annealing behavior of the HfO₂ thin film. Since with the temperature HfO₂ undergoes a polymorphic structural transition [10] from monoclinic (RT-1443 K) to tetragonal (1443–2643 K) to cubic (> 2645 K), it is imperative to study the structural transformation of fibrous HfO₂ in this temperature range.

In this present work we studied the fibrous HfO₂ doped with ¹⁸¹Hf/¹⁸¹Ta probe using the time differential perturbed angular correlation (TDPAC) technique where ¹⁸¹Ta occupying the Hf sites acted as a TDPAC probe. We annealed HfO₂ fibrous samples at different temperatures in 1000–2000 K range and investigated the structural aspects in the samples annealed at such high temperatures using TDPAC technique. Due to the fact that the available data on bulk HfO₂ having monoclinic structure [11,12] with the unit cell dimensions as a=5.1156 (5) Å, b=5.1722 (5) Å and c=5.2948 (5) Å shows a wide variation in the measured

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quadrupole frequency [13–16], we also experimentally determined the TDPAC parameters for the bulk HfO₂ samples prepared by the precipitation of hafnium hydroxide labeled with ¹⁸¹Hf tracer followed by heating it at 1173 K for 6 h. With a comparative study with the bulk sample, TDPAC data would also indicate any structural change that may have occurred while the fibers of HfO₂ are formed or during the annealing process.

In order to understand the TDPAC results obtained from the 181 Ta doped HfO₂ fibrous sample and also the annealing effects on these samples, we performed the first principle electronic structure calculations based on density functional theory (DFT) [17] using WIEN2K code [18]. We first studied the electronic structures of the bulk HfO₂ as we expect that understanding the electronic distribution around the probe 181 Ta and sources contributing to the electric field gradient (EFG) at the probe site in a bulk sample would lead to a better understanding of the changes that would occur when a fiber or the thin film of HfO₂ is prepared and annealed thereafter.

2. Experimental

2.1. Sample preparation

The HfO₂ fiber (make: Zicar Zirconia Inc., USA; purity: 99 wt%) of diameter 6–7 µm and density 1.21 g/cm³ was used in the present experiment. ¹⁸¹Hf tracer was produced by ¹⁸⁰Hf (n, γ)¹⁸¹Hf irradiating HfO₂ fiber in a thermal neutron flux of 1.0×10^{13} neutrons per cm² per second in DHRUVA reactor at Bhabha Atomic Research Centre, Mumbai, India. A part of the irradiated sample was annealed at 1173 K for 6 h and the other part at 1673 K for 6 h. Then both the samples were counted for TDPAC at room temperature. The inactive counterparts of the sample, annealed under identical conditions, were used for the XRD and SEM measurements. Bulk HfO₂ was prepared by precipitating hafnium hydroxide Hf(OH)₄ from HfCl₄ solution by adding ammonia solution in presence of ¹⁸¹Hf tracer. This precipitate was centrifuged, dried and heated at 1173 K for 6 h. This sample was then counted on the TDPAC setup mentioned below.

2.2. TDPAC measurement

Four samples viz. unannealed, annealed at 1173 K and 1673 K and the bulk HfO_2 were counted with the fast–slow coincidence of 133–482 keV cascade of the probe ¹⁸¹Ta using a coincidence system consisting of three BaF₂ detectors. The coincidence data acquisition was performed in the LIST mode with the help of a CAMAC electronics mentioned elsewhere [19]. Individual time spectra at 90° and 180° angles were obtained by applying the cascade energy gates through software in the post-acquisition period. The time resolution of the setup was 0.9 ns (FWHM) in the 133–482 KeV cascade gate.

The Nuclear Quadrupole Interaction (NQI) of the I=5/2 intermediate state leads to a splitting in three substates with $m = \pm 1/2$, $\pm 3/2, \pm 5/2$. The perturbation function is given by [20]

$$G_2(t) = a_0 + a_1 \cos \omega_1 t + a_2 \cos \omega_2 t + a_3 \cos \omega_3 t$$

with the transition frequencies among these levels are ω_1 , ω_2 and ω_3 which can be expressed in terms of the quadrupole frequency.

$$\omega_{\rm Q} = \frac{e Q V_{zz}}{40\hbar}$$

with Q denoting the quadrupole moment of the intermediate state and V_{zz} being the largest component of the field gradient tensor. The experimental data were fitted with this function modified using a finite distribution of ω_Q . In the present case we have used the Lorentzian distribution. The final form of the theoretical function in which the experimental data were fitted is given by

$$G_2(t) = a_0 + \sum_{n=1}^{3} a_n \exp(-\omega_n \delta t) \times \exp(-1/2\omega_n^2 \tau^2) \cos(\omega_n t)$$

The exponential damping terms attribute to the finite resolving time characterized by a Gaussian distribution with a standard deviation τ and the Lorentzian frequency distribution relative to width parameter δ . The coefficients a_n have dependence on the nuclear radiation parameters and the asymmetry parameter $\eta = (V_{xx} - V_{yy})/V_{zz}$.

3. Theoretical calculation

Ab-initio study of the Ta-doped HfO2 bulk samples has recently been done [21] where the effect on EFG parameters around the probe atom due to the charge state considerations has been observed but it has not been elucidated. In the present work, we have performed the electronic structure calculations based on the density functional theory (DFT) and used the augmented plane wave plus local orbital (APW+LO) method as embodied in the WIEN2K code [18] in order to understand the effect of charge state on the EFG parameters. The exchange and correlation effects were included in our calculation using Generalized Gradient Approximation (GGA) [22]. The basic input requirement for these electronic structure calculations of a crystal are the cell settings and lattice parameters. These required structure parameters used in our calculations are the same as mentioned earlier. The crystal structure of HfO₂ is monoclinic where there are four HfO₂ molecules in each unit cell and each Hf metal ion is surrounded by seven oxygen atoms. Since the doping of HfO₂ samples with ¹⁸¹Ta probes for the TDPAC studies were produced by irradiating the HfO₂ samples with thermal neutrons, the recoil of the probe nucleus is negligible. However, the recoil due to the prompt gamma emission cannot be neglected. Though there is an evidence of recoil induced damage [9], it is expected that these will be removed when the sample is annealed at high temperatures in the present experiment. As we know that the electric field gradient which determines the hyperfine parameters is extremely sensitive to the electronic environment around the probe site, the charge state of the probe atom is of prime consideration. In order to decide whether Ta would remain in 5+ state at the probe site as it would exist in a pure tantalum compound or there would be a change in the charge state of the probe Ta atom, we performed two independent calculations. In one case we assumed no change in the charge state of the dopant Ta atom as it replaced Hf atom and called it as neutral state calculations. We found partially filled impurity levels having Ta "d" and oxygen "p" character. In the second case referred to as the charge state calculation, we assumed that tantalum would act as a donor impurity. So, we removed one valence electron from the unit cell, neutralized the charge by adding one electron to the homogeneous negative background and thereafter performed the self-consistent calculations. It is interesting to note that the variation in EFG parameter around the probe atom Ta considering the neutral and charge state configurations is in agreement with the earlier work [21]. There is a speculation that Ta exists in two different charge states in Ta-doped monoclinic HfO2 and considerable amount of the magnetic moment can be induced depending on impurity charge state [23]. We determined the V_{zz} component of EFG for different *l*-projected states and studied the contribution to EFG at Ta site from the electrons having different l-values.

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